Supporting information

Controllable synthesis of Ni(OH)₂/Co(OH)₂ hollow nanohexagons wrapped by reduced graphene oxide for supercapcitors

Xinruo Su,¹ Changzhong Gao,¹ Ming Cheng,¹ Rongming Wang^{2,*}

¹ Department of Physics, Beihang University, Beijing 100191, P. R. China.

² School of Mathematics & Physics, University of Science and Technology Beijing,

Beijing 100083, P. R. China

Table S1. Specific capacitance, equivalent series resistance and charge transfer resistance of hollow nanohexagons with different rGO concentrations.

Concentration of rGO	Specific capacitance	Equivalent	Charge transfer
(µg/mL)	(F/g)	series resistance	resistance
		(Ω)	(Ω)
0	358.7	1.519	0.210
0.6	504.9	0.553	0.142
1.0	1292.8	0.338	0.086
1.4	526.7	0.375	0.268
2.0	432.2	0.394	0.279



Figure S1. XPS spectrum of the Ni(OH)₂/Co(OH)₂ hollow nanohexagons with and without rGO, respectively.



Figure S2. Time-dependent SEM images of the formation process of hollow nanohexagons wrapped by rGO.



Figure S3. Galvanostatic discharge curves of hollow nanohexagons electrodes without rGO at a current density of 1 and 10 A/g, respectively;



Figure S4. Morphology images of $Ni(OH)_2/Co(OH)_2$ hollow nanohexagons with 0.6 µg/mL rGO and its (b) CV curves in different scan rates and (c) CP curves in different current densities.



Figure S5. Morphology images of $Ni(OH)_2/Co(OH)_2$ hollow nanohexagons with 1.4 µg/mL rGO and its (b) CV curves in different scan rates and (c) CP curves in different current densities.



Figure S6. Morphology images of $Ni(OH)_2/Co(OH)_2$ hollow nanohexagons with 2.0 µg/mL rGO and its (b) CV curves in different scan rates and (c) CP curves in different current densities.